

Certificate Number: 0750.01

# SCOPE OF ACCREDITATION TO ISO/IEC 17025:2017 & ANSI/NCSL Z540-1-1994 & ANSI/NCSL Z540.3-2006

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#### **CALIBRATION**

Valid To: See details on footnote

In recognition of the successful completion of the A2LA evaluation process, process (including an assessment of the organization's compliance to A2LA's Calibration Program Requirements), accreditation is granted to this laboratory to perform the following calibrations<sup>1, 15</sup>:

#### I. Dimensional

| Parameter/Equipment                 | Range <sup>4</sup>              | CMC <sup>2, 5</sup> (±)  | Comments                      | Location |
|-------------------------------------|---------------------------------|--|-------------------------------|----------|
| Adjustable Parallels                | (0.375 to 3.00) in (9 to 75) mm | 40 μin<br>1.0 μm   | Mu-checker                    | Chicago  |
| Angle Gages                         | (5 to 180)°                     | 2.2 arc min  | Optical comparator            | Chicago  |
| Angle Gage Blocks                   | Up to 90°                       | 0.56 arc sec   | СММ                           | Chicago  |
| Calipers <sup>7</sup>               | Up to 80 in<br>Up to 2000 mm    | $(120 + 1.0L) \mu in$<br>$(3.1 + 1.0L) \mu m$<br>$(120 + 1.3L) \mu in$<br>$(3.1 + 1.3L) \mu m$ | Gage blocks & caliper checker | Chicago  |
| Caliper Gages<br>(Inside / Outside) | Up to 7.2 in<br>Up to 183 mm    | (7.1 + 3.2L) μin<br>(0.2 + 3.2L) μin   | Gage blocks                   | Chicago  |

Page 1 of 15

| Parameter/Equipment   | Range <sup>4</sup>                     | CMC <sup>2, 5</sup> (±)                          | Comments                   | Location   |
|---|--|--|----------------------------|------------|
| Check Masters/Caliper<br>Checkers/ Step Gages –                               | Up to 12 in<br>Up to 300 mm            | $(6.0 + 0.5L) \mu in$<br>$(0.15 + 0.5L) \mu m$   | Gage blocks                | Chicago    |
|   | Up to 40 in<br>Up to 1000 mm           | $(10 + 0.5L) \mu in$<br>$(0.25 + 0.50L) \mu m$   | CMM                        |            |
|   | (> 40 to 60) in<br>(> 1000 to 1500) mm | $(10 + 0.70L) \mu in$<br>$(0.25 + 0.70L) \mu m$  | CMM                        |            |
|   | Up to 80 in<br>Up to 2000 mm           | $(70 + 2.0L) \mu in$<br>$(1.8 + 2.0L) \mu m$     | CMM                        | Cincinnati |
| Circle Chart<br>(Chart 009)   | (0.002 to 26) mm                       | 0.050 μm   | Vision CMM                 | Chicago    |
| Coating Thickness Gage<br>(Digi-Derm & Lamina<br>Checker)                     | (0.0005 to 0.060) in (0.013 to 1.5) mm | 20 μin<br>0.5 μm                                 | Master films               | Chicago    |
| Coordinate Measuring<br>Machines (CMM) &<br>Vision Instruments <sup>3</sup> – |  |  |                            |            |
| Length Accuracy   | (0 to 1000) mm                         | $(0.11 + 0.13L) \mu m$                           | Gage blocks <sup>9</sup>   | Chicago    |
|   | (0 to 1000) mm                         | $(0.25 + 0.51L) \mu m$                           | Step gage <sup>9</sup>     |            |
|   | (0 to 5000) mm                         | 0.71 <i>L</i> μm                                 | He-Ne laser <sup>9</sup>   |            |
|   | (0 to 350) mm<br>(> 350 to 1000) mm    | $(0.10 + 0.12L) \mu m$<br>$(0.06 + 0.25L) \mu m$ | Linescale <sup>10</sup>    |            |
|   | (0 to 150) mm                          | $(0.060 + 0.67L) \mu m$                          | Gage blocks <sup>10</sup>  |            |
| Probe Performance   | (10 to 51) mm                          | 0.026 μm   | Sphere <sup>11</sup>       |            |
|   | (2 to 4) mm                            | 0.20 μm  | Circle chart <sup>10</sup> |            |
| Scanning Performance  | (24.9 to 25.5) mm                      | 0.026 μm   | Sphere <sup>13</sup>       |            |
| Multiple Stylus   | (10 to 51) mm                          | 0.026 μm   | Sphere <sup>11</sup>       |            |
| Rotary Axis<br>Performance  | (10 to 30) mm                          | 0.026 μm   | Sphere <sup>12</sup>       |            |
| Squareness  | (0 to 600) mm                          | $(0.076 + 0.70L) \mu m$                          | Square <sup>10</sup>       |            |
| Video Probe   | (0.02 to 4) mm                         | 0.50 μm  | Pixel chart                |            |
| Magnification Offset  | 0.5x to 30x                            | 1.2 μm   | Pixel chart                |            |

| Parameter/Equipment                  | Range <sup>4</sup>                | CMC <sup>2, 5</sup> (±)                                | Comments                         | Location      |
|--------------------------------------|-----------------------------------|--|----------------------------------|---------------|
| Cylindrical Squares                  |                                   |  |                                  |               |
| Parallelism                          | (1 to 20.7) in (25 to 550) mm     | 0.25 μin/in<br>0.25 μm/m                               | Roundness tester reversal method | Chicago       |
| Squareness                           | (0 to 20.7) in (0 to 550) mm      | 8 μin<br>0.20 μm                                       | Roundness tester                 |               |
| Roundness                            | (0 to 20.7) in<br>(0 to 550) mm   | 4 μin<br>0.10 μm                                       | Roundness tester                 |               |
| Depth Gages (Caliper,<br>Micrometer) | (0 to 40) in<br>(0 to 1000) mm    | (6+2.3L) µin $(0.15+2.3L)$ µm                          | Gage blocks                      | Chicago       |
|                                      |                                   | $(30 + 1.7L) \mu in$<br>$(0.8 + 1.7L) \mu m$           |                                  | LA            |
| Dial & Test Indicators               | (0 to 0.2) in (0 to 5) mm         | 20 μin<br>0.55 μm                                      | Dial calibration tester          | Chicago<br>LA |
|                                      | (> 0.2 to 2) in<br>(> 5 to 50) mm | 160 μin<br>4.0 μm                                      |                                  |               |
|                                      | (0 to 4) in<br>(0 to 100) mm      | $(6.0 + 5.0L) \mu in$<br>$(0.15 + 5.0L) \mu m$         | I-checker                        | Chicago       |
| Dial Indicator Tester                | (0 to 0.2) in<br>(0 to 5) mm      | 10 μin<br>0.25 μm                                      | Gage blocks                      | Chicago<br>LA |
|                                      | (0 to 2.4) in (0 to 60) mm        | 30 μin<br>0.8 μm                                       |                                  |               |
| Digimatic Indicators <sup>7</sup>    | (0 to 2.4) in<br>(0 to 60) mm     | (6.5 + 2.0 <i>L</i> ) μin<br>(0.17 + 2.0 <i>L</i> ) μm | Gage blocks                      | Chicago<br>LA |
| Digital Protractor                   | Up to 90°                         | 0.10°  | Sine bar & gage blocks           | Chicago       |
| Films (Plastic)                      | (0 to 0.250) in (0 to 6) mm       | 20 μin<br>0.5 μm                                       | Linear measuring machine         | Chicago       |

| Parameter/Equipment  | Range <sup>4</sup>                    | CMC <sup>2, 5</sup> (±)                           | Comments                            | Location      |
|--|---------------------------------------|---|-------------------------------------|---------------|
| Gage Blocks  |                                       |   |                                     |               |
| Length   | (0.004 to 0.09) in (0.1 to 0.5) mm    | 1.8 μin<br>0.05 μm                                | Gage blocks                         | Chicago       |
|  | (> 0.01 to 4) in<br>(> 0.5 to 100) mm | $(1.3 + 0.22L) \mu in$<br>$(0.033 + 0.22L) \mu m$ |                                     |               |
|  | (> 4 to 20) in<br>(> 100 to 500) mm   | $(0.7 + 0.95L) \mu in$<br>$(0.02 + 0.95L) \mu m$  | CMM                                 |               |
| Parallelism<br>(Variation in<br>Length)  | (> 20 to 40) in<br>(> 500 to 1000) mm | $(10 + 0.5L) \mu in$<br>$(0.25 + 0.5L) \mu m$     | Gage blocks                         |               |
| Deliguity  | (0.004 to 4) in<br>(0.5 to 100) mm    | 0.60 μin<br>0.015 μm                              |                                     |               |
| Central Length<br>Difference <sup>8</sup>                                      | (> 4 to 20) in<br>(> 100 to 500) mm   | 3.0 μin<br>0.08 μm                                | Comparison between gage block pairs |               |
|  | (0.05 to 4) in<br>(0.5 to 100) mm     | $(1.0 + 0.2L) \mu in$<br>$(0.025 + 0.2L) \mu m$   | Pane                                |               |
| Gage Block<br>Comparators <sup>3</sup>   | Up to 100 mm                          | 1.0 μin<br>0.025 μm                               | Gage blocks                         | Chicago       |
| Height Gages <sup>7</sup> (Including Heightmatic, QM-Height & Linear Height) – |                                       |   |                                     |               |
| Length   | Up to 24 in<br>Up to 610 mm           | $(18 + 0.90L) \mu in$<br>$(0.46 + 0.90L) \mu m$   | Step gage                           | Chicago<br>LA |
|  | Up to 40 in<br>Up to 1000 mm          | $(36 + 1.2L) \mu in$<br>$(0.91 + 1.2L) \mu m$     | Height master                       | Chicago       |
|  | Up to 40 in<br>Up to 1000 mm          | $(36 + 1.5L) \mu in$<br>$(0.91 + 1.5L) \mu m$     |                                     | LA            |
| Straightness   | Up to 24 in<br>Up to 610 mm           | 60 μin<br>1.5 μm                                  | Master square                       | Chicago<br>LA |
| Perpendicularity   | Up to 24 in<br>Up to 610 mm           | $(30 + 1.6L) \mu in$<br>$(0.76 + 1.6L) \mu m$     | Master square                       |               |

| Parameter/Equipment                       | Range <sup>4</sup>                   | CMC <sup>2, 5</sup> (±)                                | Comments           | Location      |
|---|--------------------------------------|--|--------------------|---------------|
| Height Masters                            | Up to 40 in<br>Up to 1000 mm         | $(6.0 + 0.93L) \mu in$<br>$(0.15 + 0.93L) \mu m$       | Master gage blocks | Chicago       |
|   | Up to 40 in<br>Up to 1000 mm         | $(3.0 + 2.2L) \mu in$<br>$(0.08 + 2.2L) \mu m$         |                    | LA            |
| I-Checker (Indicator<br>Tester)           | Up to 4 in<br>Up to 100 mm           | (2.2 + 1.0 <i>L</i> ) μin<br>(0.06 + 1.0 <i>L</i> ) μm | Gage blocks        | Chicago       |
| Laser Scan<br>Micrometer                  | Up to 4 in<br>Up to 100 mm           | $(13 + 3.2L) \mu in$<br>$(0.33 + 3.2L) \mu m$          | Pin gages          | Chicago       |
|   | Up to 4 in<br>Up to 100 mm           | $(13 + 3.3L) \mu in$<br>$(0.33 + 3.3L) \mu m$          |                    | LA            |
| Length Standards/<br>Micrometer Standards |                                      |  |                    |               |
| Flat End                                  | Up to 60 in<br>Up to 1500 mm         | $(6.0 + 1.6L) \mu in$<br>$(0.15 + 1.6L) \mu m$         | Gage blocks        | Chicago       |
| Spherical End                             | Up to 60 in<br>Up to 1500 mm         | $(30 + 1.6L) \mu in$<br>$(0.76 + 1.6L) \mu m$          |                    |               |
| Line Scales                               | Up to 16 in<br>Up to 410 mm          | $(10 + 0.6L) \mu in$<br>$(0.25 + 0.6L) \mu m$          | Vision CMM         | Chicago       |
|   | (> 16 to 24) in<br>(> 410 to 610) mm | $(10 + 0.9L) \mu in$<br>$(0.25 + 0.9L) \mu m$          |                    |               |
|   | Up to 40 in<br>Up to 1000 mm         | $(10 + 0.5L) \mu in$<br>$(0.25 + 0.5L) \mu m$          | СММ                |               |
| Linear Gage with Counter <sup>7</sup>     | Up to 2.00 in<br>Up to 50 mm         | $(7.2 + 1.5L) \mu in$<br>$(0.18 + 1.5L) \mu m$         | Gage blocks        | Chicago<br>LA |
|   |                                      | $(7.1 + 2.0L) \mu in$<br>$(0.18 + 2.0L) \mu m$         |                    |               |
| Litematic                                 | Up to 2 in<br>Up to 50 mm            | $(2.0 + 0.5L) \mu in$<br>$(0.05 + 0.5L) \mu m$         | Gage blocks        | Chicago<br>LA |

| Parameter/Equipment                                    | Range <sup>4</sup>                        | CMC <sup>2, 5</sup> (±)                               | Comments                               | Location      |
|--|---|---|--|---------------|
| Micrometer Heads                                       | Up to 2 in<br>Up to 51 mm                 | 3 μin<br>0.08 μm                                      | Linear measuring machine               | Chicago       |
| Micrometers <sup>7</sup> –                             | Up to 1 in<br>Up to 25 mm                 | 4.0 μin<br>0.10 μm                                    | Gage blocks                            | Chicago<br>LA |
| Outside/Inside/Tubular/<br>Indicating &<br>Snap/Groove | (1 to 80) in<br>(25 to 2000) mm           | $(6.0 + 2.0L) \mu in$<br>$(0.15 + 2.0L) \mu m$        |  |               |
| Microscope –   |   |   |  |               |
| Linearity (X & Y)                                      | Up to (16 x 8) in<br>Up to (400 x 200) mm | (52 + 1.2 <i>L</i> ) μin<br>(1.3 + 1.2 <i>L</i> ) μm  | Stage micrometer scale & angle reticle | Chicago       |
| Magnification  | 1x to 100x                                | 80 μin or 2.0 μm                                      |  |               |
| Angular  | Up to 360°                                | 1.5 arc min   |  |               |
| Mu-Checker/Amplifier                                   | Up to 0.05 in<br>Up to 1.5 mm             | 6.0 μin<br>0.15 μm                                    | Gage blocks                            | Chicago<br>LA |
| Optical Flats/Parallels                                |   |   |  |               |
| Flatness   | (0.5 to 12) in (4 to 300) mm              | 2.0 μin<br>0.050 μm                                   | Master optical flat                    | Chicago       |
|  | (0.5 to 16) in<br>(4 to 400) mm           | $(1.1 + 0.3D) \mu in$<br>$(0.28 + 0.3D) \mu m$        | Roundness tester                       |               |
| Parallelism  | (0.5 to 2) in<br>(4 to 50) mm             | 5.0 μin<br>0.13 μm                                    | Gage blocks                            |               |
| Overlay Charts –<br>Length                             | Up to 16 in<br>Up to 400 mm               | (22 + 5.0 <i>D</i> ) μin<br>(0.55 + 5.0 <i>D</i> ) μm | Vision CMM                             | Chicago       |
| Angle  | Up to 360°                                | 15 arc sec  |  |               |
| Parallel Bars  | (1 to 6) in<br>(25 to 150) mm             | 40 μin<br>1.0 μm                                      | Mu-checker                             | Chicago       |

| Parameter/Equipment                      | Range <sup>4</sup>                | CMC <sup>2, 5</sup> (±)                              | Comments                                | Location |
|--|-----------------------------------|--|---|----------|
| Pins/Plugs/Spheres/<br>Balls/Hemispheres |                                   |  |   |          |
| Diameter                                 | Up to 2 in<br>Up to 50 mm         | $(5.0 + 0.7D) \mu in$<br>$(0.13 + 0.7D) \mu m$       | Linear measuring machine & master plugs | Chicago  |
|  | (> 2 to 6) in<br>(> 50 to 150) mm | $(5.0 + 0.9D) \mu in$<br>$(0.13 + 0.9D) \mu m$       | prago                                   |          |
| Roundness                                | Up to 16 in<br>Up to 400 mm       | $(0.80 + 0.60H) \mu in$<br>$(0.02 + 0.60H) \mu m$    | Roundness tester                        |          |
|  | (0.5 to 2) in<br>(4 to 50) mm     | 0.20 μin<br>0.0050 μm                                | Reversal method on roundness tester     |          |
| Pitch Micrometer<br>Standard             | (1 to 6) in<br>(1 to 150) mm      | (67 + 8.0 <i>L</i> ) μin<br>(1.7 + 8.0 <i>L</i> ) μm | Linear measuring machine                | Chicago  |
| Pixel Calibration Charts                 | Up to 0.16 in<br>Up to 4 mm       | $(10 + 0.6L) \mu in$<br>$(0.25 + 0.6L) \mu m$        | Vision CMM                              | Chicago  |
| Precision Levels                         | (5 to 16) in<br>(100 to 406) mm   | 150 μin<br>4 μm                                      | Sine bar & gage<br>blocks               | Chicago  |
| Precision Sine Plates –                  | Up to 10 in<br>Up to 250 mm       | 5.5 arc sec  | Gage & angle blocks                     | Chicago  |
| Precision Vise                           | Up to 6 in<br>Up to 150 mm        | 40 μin<br>1.0 μm                                     | Linear height &<br>Mu-checker           | Chicago  |
| Protractor                               | Up to 180°                        | 1.5 arc min  | Optical comparator                      | Chicago  |
| Projectors <sup>3, 7</sup> –             |                                   |  |   |          |
| Squareness                               | Up to 150 mm                      | $(0.63 + 1.7L)  \mu \text{m}$                        | Steel square                            | Chicago  |
| Length Accuracy                          | Up to 300 mm                      | $(1.3 + 0.3L) \mu m$                                 | Glass scale                             |          |
| Magnification                            | 0x to 50x                         | 0.01 %   | Glass scales                            |          |

| Parameter/Equipment              | Range <sup>4</sup>                    | CMC <sup>2, 5</sup> (±)                              | Comments                                     | Location |
|----------------------------------|---------------------------------------|--|--|----------|
| Radius Gages                     | (0.01 to 2) in<br>(0.25 to 50) mm     | 0.000 50 in<br>0.013 mm                              | Optical comparator                           | Chicago  |
| Reticles                         | Up to 1 in<br>Up to 25 mm             | 60 μin<br>1.5 μm                                     | Vision CMM                                   | Chicago  |
| Ring Gages                       | (0.6 to 4) in<br>(15 to 100) mm       | $(6.0 + 1.3D) \mu in$<br>$(0.15 + 1.3D) \mu m$       | Linear measuring machine & master ring gages | Chicago  |
|                                  | (0.04 to 21) in (1 to 535) mm         | $(9.4 + 0.7D) \mu in$<br>$(0.24 + 0.7D) \mu m$       | СММ  |          |
| Riser Blocks                     | Up to 24 in<br>Up to 600 mm           | $(4.3 + 1.0H) \mu in$<br>$(0.11 + 1.0H) \mu m$       | Gage blocks                                  | Chicago  |
|                                  |                                       | $(2.5 + 2.3H) \mu in$<br>$(0.06 + 2.3H) \mu m$       |  | LA       |
| Screw Pitch Gages (Leaf<br>Type) | (4.0 to 84.0) TPI<br>(0.25 to 7.0) mm | 250 μin<br>7 μm                                      | Optical comparator                           | Chicago  |
| Screw Thread Anvils              | 60° & 55°                             | 0.4°   | Optical comparator                           | Chicago  |
| Sine Bars                        | Up to 40 in<br>Up to 1000 mm          | $(10 + 0.5L) \mu in$<br>$(0.25 + 0.5L) \mu m$        | СММ  | Chicago  |
| Squares                          | Up to 24 in<br>Up to 610 mm           | (12 + 5.1 <i>L</i> ) μin<br>(0.3 + 5.1 <i>L</i> ) μm | Master square                                | Chicago  |
|                                  | Up to 40 in<br>Up to 1000 mm          | $(3.0 + 0.70L) \mu in$<br>$(0.076 + 0.70L) \mu m$    | CMM using reversal technique                 |          |

| Parameter/Equipment | Range <sup>4</sup>      | CMC <sup>2, 5</sup> (±) | Comments               | Location   |
|---------------------|-------------------------|-------------------------|------------------------|------------|
| Specialty Gages –   |                         |                         |                        |            |
| 1D Length           | Up to 100 mm            | $(0.058 + 0.81L) \mu m$ | Contact methods        | Chicago    |
|                     | (> 100 to 500) mm       | $(0.061 + 0.9L) \mu m$  | Contact methods        | Chicago    |
|                     | (> 500 to 1000) mm      | $(0.25 + 0.50L) \mu m$  | Contact methods        | Chicago    |
|                     | Up to 400 mm            | $(0.25 + 0.60L) \mu m$  | Non-contact methods    | Chicago    |
|                     | Up to 600 mm            | $(1.8 + 3.7L) \mu m$    | Non-contact<br>methods | Cincinnati |
|                     | Up to 2000 mm           | $(1.8 + 2.0L) \mu m$    | Contact methods        | Cincinnati |
| 2D Length           | (400 x 400) mm          | $(0.5 + 2.2L) \mu m$    | Non-contact<br>methods | Chicago    |
|                     | (600 x 600) mm          | $(1.8 + 4.8L) \mu m$    | Non-contact methods    | Cincinnati |
|                     | (900 x 1000) mm         | $(0.43 + 1.3L) \mu m$   | Contact methods        | Chicago    |
| 3D Length           | (1200 x 2000x1000) mm   | $(2.8 + 3.5L) \mu m$    | Contact methods        | Cincinnati |
|                     | (900 x 1000 x 600) mm   | $(0.43 + 1.3L) \mu m$   | Contact methods        | Chicago    |
| Form                | (1200 x 2000 x 1000) mm | $(2.8 + 3.5L) \mu m$    | Contact methods        | Cincinnati |
|                     | Up to 50 mm             | 0.005 μm                | Roundness tester       | Chicago    |
|                     | (> 50 to 550) mm        | 0.025 μm                | Roundness tester       | Chicago    |
|                     | Up to 500 mm            | $(0.02 + 0.47L) \mu m$  | Contact methods        | Cincinnati |
|                     | Up to 1000 mm           | 0.050 μm                | CMM                    | Chicago    |
|                     | Up to 2000 mm           | $(2.8 + 3.5L) \mu m$    | Contact methods        | Cincinnati |
| Surface Finish      | Ra (0 to 1.0) μm        | 0.02 μm                 | Surface roughness      | Chicago,   |
|                     | Ra (> 1.0 to 12.7) μm   | 1.2 % of nominal value  | tester                 | Cincinnati |

| Parameter/Equipment                                       | Range <sup>4</sup>  | CMC <sup>2, 5</sup> (±)                          | Comments                                 | Location |
|---|---|--|--|----------|
| Step Height Specimen                                      | (0.01 to 0.120) in (0.25 to 3) mm   | 4.5 μin<br>0.12 μm                               | Gage block comparator                    | Chicago  |
| Straightedge  | Up to 21.7 in Up to 550 mm  Up to 21.7 in   | 8.0 μin<br>0.20 μm<br>1.0 μin                    | Roundness tester  Reversal method on     | Chicago  |
|   | Up to 550 mm Up to 40 in Up to 1000 mm  | 0.025 μm<br>2.0 μin<br>0.050 μm                  | roundness tester  Reversal method on CMM |          |
| Surface Finish & Form Measuring Instruments <sup>3,</sup> |   |  |  |          |
| Detector Accuracy   | (-30 to 30) mm  | $(0.052 + 0.6L) \mu m$                           | Gage blocks                              | Chicago  |
| Straightness  | Up to 550) mm   | 0.025 μm   | Straightedge                             |          |
| Radial Motion   | Up to 360°  | 0.0050 μm  | Precision sphere                         |          |
| Axial Motion  | Up to 360°  | 0.0010 μm  | Precision sphere                         |          |
| Parallelism   | (10 to 550) mm  | 0.13 μm/m  | Cylindrical square                       |          |
| Squareness  | (10 to 100) mm  | 0.28 μm/m  | Square reversal                          |          |
| Length  | Up to 200 mm  | $(0.5 + 0.7L) \mu m$                             | Pitch gage                               |          |
|   | Up to 550 mm  | (0.71 <i>L</i> ) μm                              | He-Ne laser                              |          |
| Surface Finish  | Up to 10 μm<br>Up to 400 μin  | 0.02 μm<br>0.8 μin                               | Surface finish specimen                  |          |
| Surface Finish<br>Specimen                                | Ra (0 to 40) μin<br>Ra (0 to 1.0) μm<br>Ra (> 40 to 500) μin<br>Ra (> 1.0 to 12.7) μm | 0.7 μin<br>0.018 μm<br>1.2 % of nominal<br>value | Surface finish tester                    | Chicago  |
| Tap & Drill Gage  | (0.001 to 0.500) in<br>(0.025 to 12.70) mm  | 250 μin<br>6.4 μm                                | Optical comparator                       | Chicago  |

| Parameter/Equipment  | Range <sup>4</sup>                        | CMC <sup>2, 5</sup> (±)  | Comments                         | Location      |
|--|---|--|----------------------------------|---------------|
| Thickness Gages<br>(Feeler Type)   | (0.001 to 0.050) in<br>(0.025 to 1.27) mm | 35 μin<br>1.0 μm   | Linear measuring machine         | Chicago       |
| Thickness Measuring<br>Gages (Digital & Dial<br>Inside – Outside Caliper<br>Gages) | Up to 2 in<br>Up to 50 mm                 | $(7.2 + 0.4L) \mu in$<br>$(0.2 + 0.4L) \mu m$<br>$(7.2 + 0.6L) \mu in$<br>$(0.2 + 0.6L) \mu m$ | Gage blocks                      | Chicago       |
| Thread Measuring Wires   | (1 to 120) TPI<br>(0.2 to 10.0 mm) Pitch  | 5.0 μin<br>0.15 μm   | Linear measuring machine         | Chicago       |
| Ultrasonic Thickness<br>Gage (Mu Gage)   | Up to 2 in<br>Up to 50 mm                 | (100 + 16 <i>L</i> ) μin<br>(2.5 + 16 <i>L</i> ) μm  | Gage blocks                      | Chicago       |
| V-Anvil Micrometers  | Up to 3.4 in<br>Up to 87 mm               | (64 + 4.0 <i>L</i> ) μin<br>(1.6 + 4.0 <i>L</i> ) μm   | Pin gages                        | Chicago<br>LA |
| V-Blocks   | Up to 4 in<br>Up to 102 mm                | 65 μin<br>1.7 μm   | Mu checker with lever head probe | Chicago       |
| Wire Gages   | (0.005 to 4) in                           | 250 μin  | Optical comparator               | Chicago       |
| 1-2-3 Blocks –  Parallelism Squareness   | (1 x 2 x 3) in                            | 35 μin or 0.90 μm<br>40 μin or 1.0 μm  | Mu-checker with lever head probe | Chicago       |

## II. Dimensional Testing<sup>1</sup>

| Parameter/Equipment                      | Range <sup>4</sup>            | Comments                 | Location               |
|--|-------------------------------|--------------------------|------------------------|
| Geometric<br>Measurements <sup>6</sup> – |                               |                          |                        |
| 1D                                       | Up to 1000 mm                 | Contact methods          | Chicago                |
|  | Up to 2000 mm                 | Contact methods          | Cincinnati             |
|  | Up to 400 mm                  | Non-contact methods      | Chicago                |
|  | Up to 600 mm                  | Non-contact methods      | Cincinnati             |
| 2D                                       | Up to (900 x 1000) mm         | Contact methods          | Chicago                |
|  | Up to (400 x 400) mm          | Non-contact methods      | Chicago                |
|  | Up to (600 x 600) mm          | Non-contact methods      | Cincinnati             |
|  | Up to (1200 x 2000) mm        | Contact methods          | Cincinnati             |
| 3D                                       | Up to (900 x 1000 x 600) mm   | Contact methods          | Chicago                |
|  | Up to (1200 x 2000 x 1000) mm | Contact methods          | Cincinnati             |
| Form                                     | Up to 1000 mm                 | Contact methods          | Chicago                |
|  | Up to 400 mm                  | Non-contact methods      | Chicago                |
|  | Up to 2000 mm                 | Contact methods          | Cincinnati             |
| Surface Finish                           | Ra Up to 12.7 μm              | Surface roughness tester | Chicago,<br>Cincinnati |

## III. Mechanical

| Parameter/Equipment                  | Range <sup>4</sup> | CMC <sup>2</sup> (±) | Comments  | Location |
|--------------------------------------|--------------------|----------------------|-----------|----------|
| Hardness Tester (Leeb<br>Scale)      | (500 to 900) HLD   | 16 HLD               | ASTM A956 | Chicago  |
| Hardness Test Blocks<br>(Leeb Scale) | (500 to 900) HLD   | 20 HLD               | ASTM A956 | Chicago  |

Page 12 of 15

| Parameter/Equipment   | Range <sup>4</sup>             | $CMC^{2}(\pm)$                               | Comments                         | Location |
|---|--------------------------------|--|----------------------------------|----------|
| Durometer Tester<br>Type A & D  | (0 to 100) Duro                | 0.60 Duro                                    | ASTM D2240                       | Chicago  |
| Indenter Length Indenter Angle Indenter Radius Indenter Tip diameter                            |                                | 200 μin<br>3.0 arc min<br>400 μin<br>400 μin | Vision CMM or optical comparator |          |
| Durometer Test Blocks<br>Type A & D   | (0 to 100) Duro                | 1.0 Duro                                     | ASTM D2240                       | Chicago  |
| Direct Verification of<br>Rockwell Hardness<br>Testers <sup>3</sup> –                           |                                |  | ASTM E18                         | Chicago  |
| Test Force  | (3 to 150) kgf                 | 0.38 % of range                              | Load cell<br>Linear gage         |          |
| Depth Measuring<br>System   | (0 to 0.2) mm                  | 0.47 μm                                      |                                  |          |
| Hysteresis  | 100 HR & 130 HR                | 0.12 HR                                      |                                  |          |
| Testing Cycle   | Up to 30 s                     | 0.10 s                                       | Stopwatch                        |          |
| Direct Verification of<br>Vickers & Knoop<br>Hardness Testers <sup>3</sup> –                    |                                |  | ASTM E92                         | Chicago  |
|   | (0.001 ( 120) 1 (              | 0.20.0/                                      | Load cell                        |          |
| Test Force  | (0.001 to 120) kgf             | 0.38 % of range<br>0.40 μm                   | Line scale                       |          |
| Indentation Measuring System  | (0 to 0.1) mm                  |  | Stopwatch                        |          |
| Testing Cycle   | Up to 30 s                     | 0.10 s                                       |                                  |          |
| Indirect Verification of<br>Rockwell & Rockwell<br>Superficial Hardness<br>Testers <sup>3</sup> | HRA:<br>High<br>Medium<br>Low  | 0.20 HRA<br>0.22 HRA<br>0.24 HRA             | ASTM E18                         | Chicago  |
|   | HRBW:<br>High<br>Medium<br>Low | 0.43 HRBW<br>0.54 HRBW<br>0.66 HRBW          |                                  |          |

| Parameter/Equipment  | Range <sup>4</sup>              | $CMC^{2}(\pm)$                            | Comments | Location |
|--|---------------------------------|---|----------|----------|
| Indirect Verification of<br>Rockwell & Rockwell<br>Superficial Hardness<br>Testers <sup>3</sup> (cont) | HRC:<br>High<br>Medium<br>Low   | 0.32 HRC<br>0.34 HRC<br>0.35 HRC          | ASTM E18 | Chicago  |
|  | HRD:<br>High<br>Medium<br>Low   | 0.40 HRD<br>0.42 HRD<br>0.51 HRD          |          |          |
|  | HR30N:<br>High<br>Medium<br>Low | 0.32 HR30N<br>0.36 HR30N<br>0.41 HR30N    |          |          |
|  | HR30TW: High Medium Low         | 0.34 HR30TW<br>0.42 HR30TW<br>0.50 HR30TW |          |          |
| Indirect Verification of Vickers & Knoop Hardness Testers <sup>3</sup>                                 |                                 |   |          |          |
| Macro V  | Low<br>Medium<br>High           | 0.12 HV<br>1.2 HV<br>2.4 HV               | ASTM E92 | Chicago  |
| Micro V  | Low<br>Medium<br>High           | 0.21 HV<br>1.8 HV<br>3.6 HV               |          |          |
| Micro K  | Low<br>Medium<br>High           | 0.5 HK<br>2.1 HK<br>2.6 HK                |          |          |

<sup>&</sup>lt;sup>1</sup> This laboratory offers commercial and field calibration and dimensional testing services.

Page 14 of 15

<sup>&</sup>lt;sup>2</sup> Calibration and Measurement Capability Uncertainty (CMC) is the smallest uncertainty of measurement that a laboratory can achieve within its scope of accreditation when performing more or less routine calibrations of nearly ideal measurement standards or nearly ideal measuring equipment. CMCs represent expanded uncertainties expressed at approximately the 95 % level of confidence, usually using a coverage factor of k = 2. The actual measurement uncertainty of a specific calibration performed by the laboratory may be greater than the CMC due to the behavior of the customer's device and to influences from the circumstances of the specific calibration.

- <sup>3</sup> Field calibration service is available for this calibration. Please note the actual measurement uncertainties achievable on a customer's site can normally be expected to be larger than the CMC found on the A2LA Scope. Allowance must be made for aspects such as the environment at the place of calibration and for other possible adverse effects such as those caused by transportation of the calibration equipment. The usual allowance for the actual uncertainty introduced by the item being calibrated, (e.g. resolution) must also be considered and this, on its own, could result in the actual measurement uncertainty achievable on a customer's site being larger than the CMC.
- <sup>4</sup> Metric equivalencies for these ranges and associated CMCs are also available.
- <sup>5</sup> In the statement of CMC, L is the length in inches/meters; D is the diameter in inches/meters; H is the height in inches/meters and R is the resolution in  $\mu$ in/ $\mu$ m.
- <sup>6</sup> This test is not equivalent to that of a calibration.
- <sup>7</sup> Repeatability of the Unit Under Test has not been utilized in the calculation of the CMC value for this measurement parameter.
- <sup>8</sup> The CMC claim is smaller than that of the expanded uncertainty claim for NIST as listed in the BIPM Key Comparison Database. A2LA has evaluated the laboratory's CMC claim and has verified this information to be correct and appropriate.
- <sup>9</sup> Calibration method in accordance to ISO 10360-2:2001 or ISO 10360-2:2009.
- <sup>10</sup> Calibration method in accordance to ISO 10360-7.
- <sup>11</sup> Calibration method in accordance to ISO 10360-5:2020 and ISO 10360-5:2010.
- <sup>12</sup> Calibration method in accordance to ISO 10360-3.
- <sup>13</sup> Calibration method in accordance to ISO 10360-4:2000 and ISO 10360-5:2020.
- <sup>14</sup> The locations of the laboratories that can perform the calibrations are given by a letter code with valid to dates given in the table below:

| Location                                       | Code       | Valid Dates |
|--|------------|-------------|
| 965 Corporate Blvd, Aurora, IL 60502           | Chicago    | 05/31/2026  |
| 16 925 E. Gale Ave, City of Industry, CA 91745 | LA         | 05/31/2024  |
| 8876 Beckett Road, West Chester, OH 45069      | Cincinnati | 10/31/2025  |

<sup>&</sup>lt;sup>15</sup> This scope meets A2LA's *P112 Flexible Scope Policy*.

A Page 15 of 15



# **Accredited Laboratory**

A2LA has accredited

## MITUTOYO AMERICA CORPORATION

for technical competence in the field of

## Calibration

This laboratory is accredited in accordance with the recognized International Standard ISO/IEC 17025:2017 General requirements for the competence of testing and calibration laboratories. This laboratory also meets the requirements of ANSI/NCSL Z540-1-1994 and the requirements of ANSI/NCSL Z540.3-2006 and R205 – Specific Requirements: Calibration Laboratory Accreditation Program. This accreditation demonstrates technical competence for a defined scope and the operation of a laboratory quality management system (refer to joint ISO-ILAC-IAF Communiqué dated April 2017).



Presented this 19th day of April 2024.

Mr. Trace McInturff, Vice President, Accreditation Services

For the Accreditation Council

Certificate Number 750.01

Valid to: See Scope of Accreditation